

REMARKS

Claims 26-51 are in this application and presented for consideration. By this Amendment, Applicant has amended Claims 26, 28, 32, 34, 39, 41, 45 and 47. Applicant has also canceled Claims 27, 33, 40 and 46.

Figures 1, 3 and 4 have been objected to because numerous values printed on the plots are overwritten with other values. Applicant has provided replacement sheet of drawings of Figures 1, 3 and 4.

Claims 26-51 have been rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which Applicant regards as the invention.

Applicant has amended Claims 26, 32, 39 and 45 paying close attention to the Examiner's remarks. The claims have been amended to clarify the scope of the resin composition and to define the variable parameters in the structure. The changes made to the claims are supported by the amended specification filed April 13, 2006 on page 4, lines 17-19:

This monoazo metal complex compound containing composition is desirably such that the purity of the aforementioned monoazo metal complex compound is not less than 90% as determined by high performance liquid chromatography.

The changes also find support in the amended specification on page 15, lines 9-20:

According to the production method of the present invention for a monoazo metal complex compound containing composition, it is possible to produce the monoazo metal complex compound containing composition of the present

invention, while remaining starting materials and impurity substances associated with monoazo dyes, byproducts and impurity substances associated with metallization of monoazo dyes, and other undesirable substances are removed efficiently. For example, naphthol AS products such as naphthol AS and naphthol AS-D, which are also used as coupling components of monoazo dyes, described with reference to the prior art above, can be removed so that a monoazo metal complex compound containing composition (generally referred to as "monoazo metal complex compound") with almost no sensitizing potential is obtained.

It is Applicant's position that the claims are definite and clear and satisfy the requirements of the statute. Accordingly, Applicant respectfully requests that the Examiner favorably consider the claims as now presented.

Further and favorable actions on the merits is requested.

Respectfully submitted
for Applicant,



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Enclosed: Three (3) Sheets of Replacement Drawings

JJM:BMD/tf

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